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# Temperature and size dependence of electron magnetic resonance spectra of Ni nanoparticles embedded in an amorphous SiO<sub>2</sub> matrix

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## Abstract

Investigations of spin dynamics in Ni nanoparticles (NPs) with diameters  $D = 3.8, 11.7, 15$  and  $21$  nm embedded in an amorphous SiO<sub>2</sub> matrix of composition 15/85 (Ni/SiO<sub>2</sub>) are reported using EMR (electron magnetic resonance) spectroscopy at 9.28 GHz. Three resonance lines are observed whose EMR parameters, namely linewidth  $\Delta H$ , resonance field  $H_r$  and intensity  $I_o$ , are measured from 5 to 300 K. Line 1 with temperature-independent  $\Delta H = 50$  Oe and  $g \approx 2$ , and intensity varying as  $1/T$ , is shown to result from paramagnetic defects in the SiO<sub>2</sub> matrix. Lines 2 and 3, with  $g \approx 2.2$  and 8, respectively, and temperature-dependent EMR parameters are assigned to Ni NPs. While line 2 with  $g \approx 2.2$  is due to the majority of Ni NPs, the source of line 3 is discussed in terms of two possibilities: (i) large clusters of blocked Ni NPs and (ii) the inherent part of the composite asymmetric line made up of lines 2 and 3 predicted by the Raikher–Stepanov (RS) model for dispersed ferromagnets. The temperature dependence of  $\Delta H$  (full width at half-maximum) of the composite line obtained by integration of the EMR spectra decreases with the increase in temperature, reaching a minimum near 300 K in agreement with the RS model. The observed decreasing asymmetry of the composite absorption spectra with increasing temperature is also in agreement with the predictions of the RS model, thus providing a satisfactory explanation for the observed temperature dependence of the EMR spectra of Ni NPs. Large clusters of blocked Ni NPs as the source of line 3 are ruled out and additional tests for the RS model are proposed. The decreasing magnetization with decreasing particle size of Ni NPs observed here is discussed in terms of the possible roles of the surface disordered spins and Ni–SiO<sub>2</sub> interaction.

## 1. Introduction

A current area of intense research activity is how the properties of magnetic nanoparticles (NPs) vary with the change in the size of NPs from about 100 nm to a few nm. This interest is driven in part by the size-dependent properties of NPs and partly by their potential applications in biomedicine [1, 2], catalysis [3] and sensors [4]. In addition to measurements of change in magnetization  $M$  with variations in temperature  $T$  and magnetic field  $H$ , ac susceptibility measurements are often used to determine the relaxation parameters. Electron magnetic resonance (EMR) spectroscopy is a complementary

technique since it provides details of spin dynamics and magnetic interactions not available from other techniques.

Bulk Ni is a classic metallic ferromagnet with Curie temperature  $T_C = 631$  K. There have been a number of studies on NPs of Ni partly because of their application in catalysis [3, 5, 6]. Reported works include magnetic susceptibility studies of Gittleman *et al* on Ni granular films sputtered on SiO<sub>2</sub> and Al<sub>2</sub>O<sub>3</sub> substrates [7], magnetic studies of Sahoo *et al* on 5 nm particles [8], magnetic studies of Zhang *et al* on 10 nm particles [9], and magnetic and ac susceptibility studies of Goya *et al* on the 3 nm Ni/SiO<sub>2</sub> system [10].

In none of the above reported studies were systematic investigations of the changes in the magnetic properties with

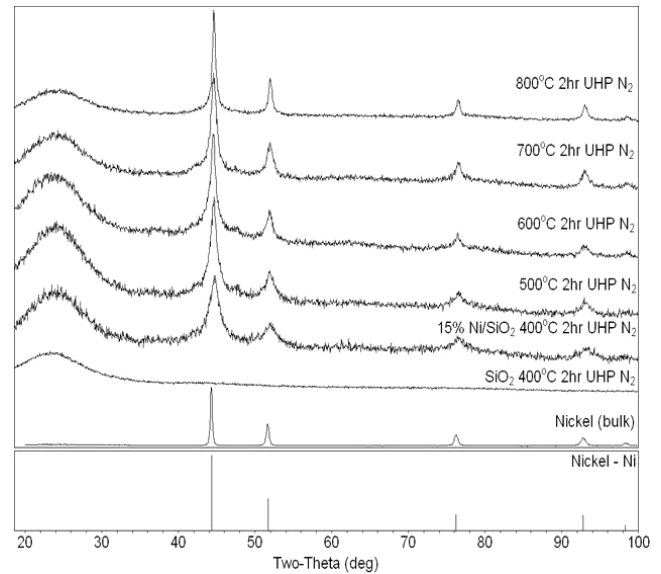
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the change in the size of the Ni NPs carried out. Recently we undertook such investigations on the Ni NPs embedded in an SiO<sub>2</sub> matrix with the nominal composition Ni/SiO<sub>2</sub> (15/85) and reported changes in the blocking temperature of the 3.8 nm NPs with applied magnetic field and measuring frequency [11]. In a subsequent paper, relaxation parameters using ac susceptibility measurements for NPs of Ni in the Ni/SiO<sub>2</sub> nanocomposite with diameters  $D = 3.8, 11.7, 15$  and 21 nm for the Ni NPs were presented [12]. In this paper, we report results on the changes in the temperature dependence of the EMR spectra measured at 9.28 GHz for the same samples with  $D = 3.8, 11.7, 15$  and 21 nm, along with their measured magnetizations up to 65 kOe. In the EMR spectra, three resonance lines are observed, two of which are assigned to Ni NPs and the third narrower line near  $g = 2.0$  is shown to be due to paramagnetic defects in the supporting amorphous SiO<sub>2</sub> matrix. The temperature dependence of the resonance field  $H_r$ , linewidth  $\Delta H$ , and intensity  $I_o$  for all three lines are investigated for the 5–300 K range. These results of  $H_r$ ,  $\Delta H$  and  $I_o$  for the two lines due to Ni are interpreted in terms of the size and temperature dependence of the magnetic anisotropy of these particles in the polycrystalline dispersed system. The asymmetry and the inhomogeneous broadening of the composite absorption line due to the Ni NPs (caused by scattering in orientation of the anisotropy axis) is progressively suppressed in the superparamagnetic region with increasing temperatures. The saturation magnetization also decreases with the decrease in the size of the NPs. Details of these results along with their interpretation and discussions are presented below.

## 2. Experimental details

The samples of Ni/SiO<sub>2</sub> (15/85) nanocomposites were synthesized by the sol–gel route using Ni(NO<sub>3</sub>)<sub>2</sub>·6H<sub>2</sub>O, TEOS (tetraethylorthosilicate), anhydrous citric acid, anhydrous ethylene glycol and ethanol [3, 10]. Briefly, Ni(NO<sub>3</sub>)<sub>2</sub>·6H<sub>2</sub>O and TEOS in appropriate amounts are added to a solution of citric acid in alcohol and homogenized at room temperature for 15 min. This is followed by adding ethylene glycol and polymerizing the solution for several hours at 80 °C, resulting in a solid resin. The solid resin is then heated in air at 300 °C for 6 h. The resulting compound is thoroughly ground by mortar and pestle and then annealed at selected temperatures between 400 and 800 °C in flowing UHP (ultrahigh pure) N<sub>2</sub> gas for 2 h to obtain particle sizes of Ni in the range of 3.8–23 nm. If ordinary grade N<sub>2</sub> is used, then some NiO was always detected in the x-ray diffraction (XRD) patterns.

The XRD patterns of the samples annealed at 400, 500, 600, 700 and 800 °C, using a Cu K $\alpha$  source with  $\lambda = 1.54185$  Å, are shown in figure 1. Except for the broad line centered near  $2\theta = 24^\circ$  due to the amorphous SiO<sub>2</sub> matrix, all the remaining lines are due to FCC Ni. The diameters  $D$  of the particles were determined from the width of the lines as well as from transmission electron microscopy (TEM) of the particles. In our other publications [11–13] TEM micrographs and resulting size distribution for various sizes were shown.



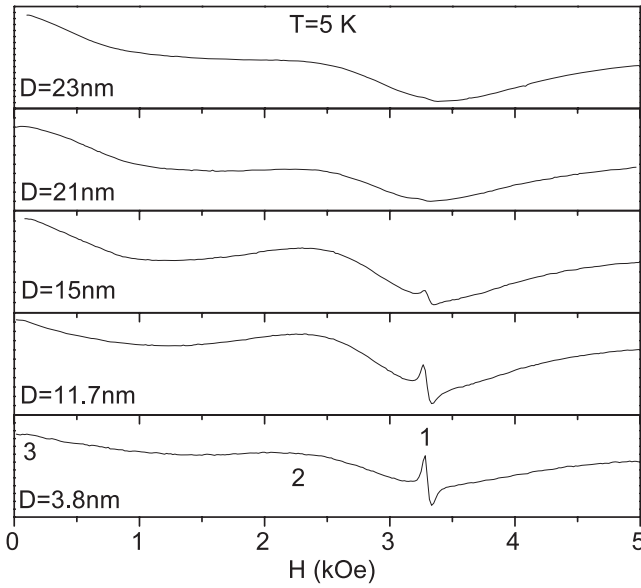
**Figure 1.** Room temperature XRD patterns of the Ni/SiO<sub>2</sub> samples annealed at various temperatures in ultrahigh pure (UHP) N<sub>2</sub> gas. For comparison, XRD of bulk Ni and expected line positions for FCC Ni are also shown.

Analysis of TEM micrographs for all five sizes yielded log-normal size distributions with mean  $D = 3.8, 11.7, 15, 21$  and 23 nm and standard deviation  $\sigma \approx 0.2$  for samples annealed at 400, 500, 600, 700 and 800 °C, respectively. Sizes determined from the Williamson–Hall analysis of the XRD data were consistent with the results from TEM [13]. Two additional samples were prepared without any Ni doping by annealing them at 400 and 800 °C to determine the nature of any background EMR signal from SiO<sub>2</sub>.

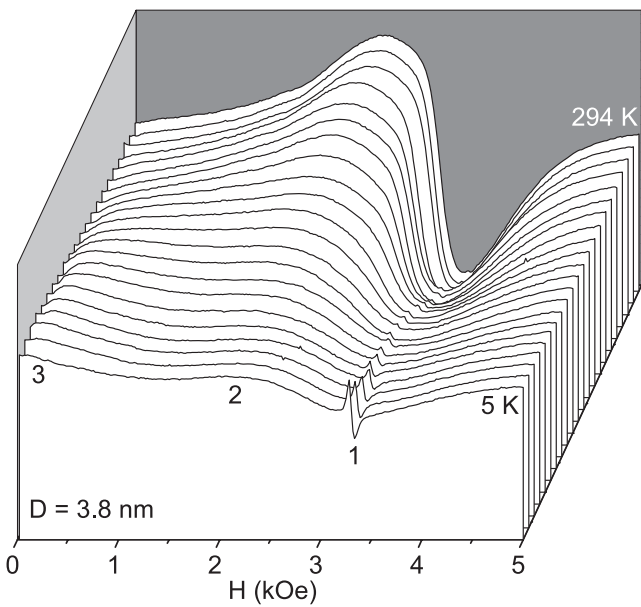
The EMR spectra at 9.28 GHz were recorded using a conventional reflection type x-band (9.28 GHz) spectrometer in conjunction with a variable-temperature cryostat (Oxford Instruments) to yield the spectra in the temperature range of 5–300 K. As usual, the recorded signals represent the first derivative of the absorption curve with respect to sweeping field  $H$  and the reported linewidths are peak-to-peak separations in the absorption derivatives. Integration of the EMR spectra to yield absorption profiles at different temperatures is also presented. Magnetizations were measured with a commercial SQUID magnetometer.

## 3. Experimental results

A comparison of the EMR first-derivative signals observed at 5 K in the five samples of different sizes is shown in figure 2. Three EMR lines are observed: (i) the narrow line 1 near  $g = 2.00$  whose intensity decreases with increase in particle size; (ii) the broad line 2 centered near  $g = 2.25$  whose signature does not appear to change with changes in particle size and (iii) absorption marked 3 at the lower fields for which only a part of the line is observed even at 5 K. The profiles of the observed EMR spectra at different temperatures from 5 K to room temperatures for two representative samples, namely samples with sizes  $D = 3.8$  and 21 nm, are shown in figures 3



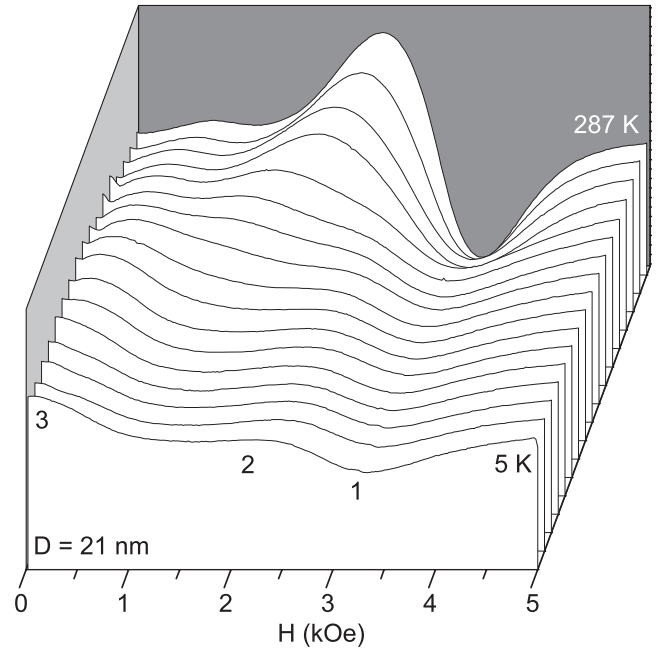
**Figure 2.** EMR absorption derivative profiles of the various Ni/SiO<sub>2</sub> samples with sizes from 3.8 to 23 nm measured at 5 K. The numbers 1, 2 and 3 label the three lines discussed in the text.



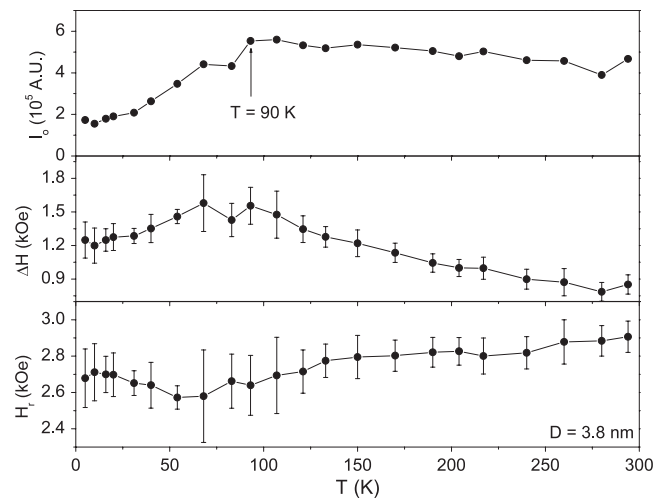
**Figure 3.** Recorded EMR line profiles for the 3.8 nm particles at  $T = 5, 10, 16, 20, 31, 40, 54, 68, 83, 93, 107, 121, 133, 150, 170, 190, 204, 217, 240, 260, 280$  and 294 K.

and 4, respectively. All the profiles in figures 3 and 4 were recorded using the same spectrometer parameters such as gain. Results for other samples are similar [13]. It is evident that the intensity of line 1 decreases with increase in temperature and with increase in particle size. For line 3, profiles shift to higher fields with increase in temperature, although the line is not well resolved. Therefore it is difficult to accurately measure its resonance field  $H_r$  and linewidth  $\Delta H$ .

For the two representative samples with sizes  $D = 3.8$  nm and 21 nm, the temperature dependence of  $H_r$ ,  $\Delta H$  and the line intensity  $I_o$  of line 2 are plotted in



**Figure 4.** Recorded EMR line profiles for the 21 nm particles at  $T = 5, 13, 18, 28, 45, 58, 70, 85, 95, 110, 122, 132, 147, 170, 190, 230$  and 287 K.



**Figure 5.** Temperature variations of the intensity  $I_o$ , linewidth  $\Delta H$  and resonance field  $H_r$  of line 2 in 3.8 nm particles are shown. The lines connecting the data points are for visual aid.

figures 5 and 6, respectively. The relation  $I_o = \alpha(\Delta H)^2 L$  is used for calculations of  $I_o$ , where  $L$  is the peak-to-peak height of the absorption derivative and  $\alpha = 3.63$  for a Lorentzian line. It is evident that the intensity  $I_o$  and linewidth  $\Delta H$  peak at a certain temperature which we associate with the blocking temperature  $T_B$  (EMR) = 90 K and 122 K for the  $D = 3.8$  nm and  $D = 21$  nm samples, respectively, followed by decreasing magnitudes of these quantities with decreasing  $T$  for  $T < T_B$ . The line positions  $H_r$  appear to have a minimum at  $T_B$  so that the lineshifts  $H_r(300 \text{ K}) - H_r(T)$  will also peak at  $T = T_B$  (EMR). These magnitudes of  $T_B$  (EMR) measured at 9.28 GHz are higher

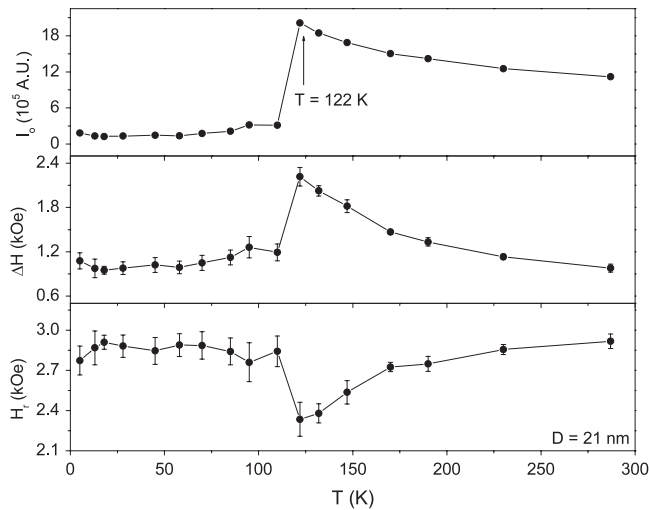


Figure 6. The same as in figure 5 except for the  $D = 21$  nm sample.

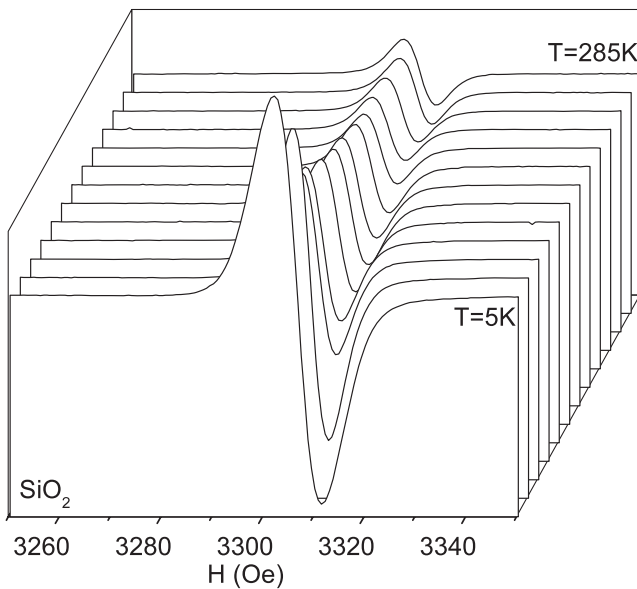


Figure 7. Line profiles of EMR spectra in the undoped  $\text{SiO}_2$  sample annealed at  $400^\circ\text{C}$ . The line profiles shown are for temperatures  $T = 5, 20, 40, 56, 70, 83, 100, 120, 155, 195, 235, 265$  and  $285$  K.

than those measured at ac frequencies  $<1$  kHz due to the measuring frequency dependence of  $T_B$  and the effect of the applied resonance field  $H_r$  [11–13]. An interpretation of the temperature variations of figures 5 and 6 is given later in this paper. Similar variations were observed for the other sizes [13].

For the sample of  $\text{SiO}_2$  prepared similarly but without any Ni doping and annealed at  $400^\circ\text{C}$ , a narrow line of width  $\Delta H = 9$  Oe and  $g = 2.00$  is observed. The EMR line profiles for this line at different temperatures are shown in figure 7 and the temperature dependence of its EMR parameters is shown in figure 8. The line intensity  $I_0$  varies nearly as  $1/T$  with  $\Delta H$  and  $H_r$  being essentially temperature-independent. For comparison, the temperature dependence of the EMR line 1 observed in the  $D = 3.8$  nm of Ni/ $\text{SiO}_2$  has a similar variation (figure 8).

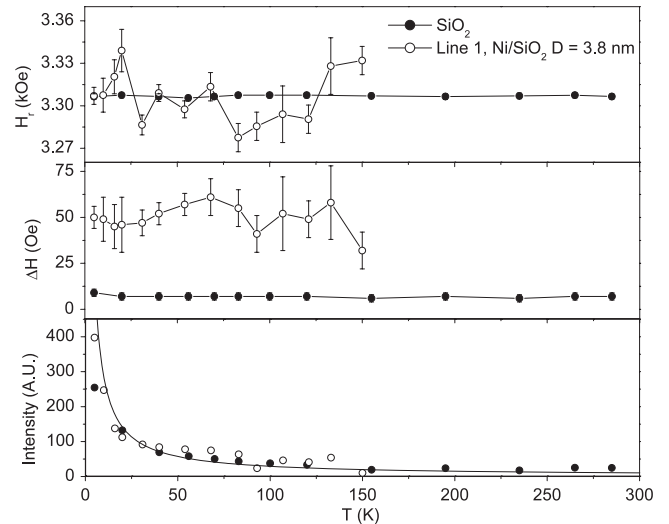


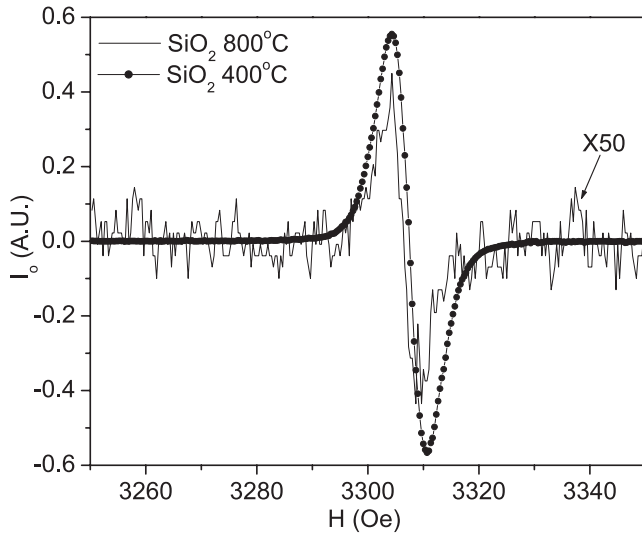
Figure 8. Temperature variations of the EMR parameters for line 1 in the undoped  $\text{SiO}_2$  annealed at  $400^\circ\text{C}$  and in the  $3.8$  nm Ni/ $\text{SiO}_2$  sample. The solid line in the bottom figure for intensity is a  $1/T$  variation. For the variation of  $H_r$  and  $\Delta H$ , lines connecting the data points are for a visual aid.

#### 4. Interpretation of line 1

As mentioned earlier, the narrow EMR line 1 (figures 2, 7 and 8) is attributed to paramagnetic defects in the  $\text{SiO}_2$  matrix for the following reasons: first, the measured  $g$  value of  $2.00$  for line 1 is different from  $g \approx 2.25$  measured and expected from Ni; and second, its temperature-independent  $\Delta H$  and  $H_r$  and  $1/T$  dependence of intensity is characteristic of paramagnetism. In a number of earlier studies of NPs of iron oxides, the observed narrow line has been attributed to superparamagnetic small nanoparticles present in the samples [14–17]. However, in those cases, the  $g = 2.00$  of the narrow line was identical to that of the main line attributed to most of the other particles. In addition, as discussed later,  $\Delta H$  and  $H_r$  for a superparamagnetic resonance are expected to be temperature-dependent, in contrast to the observations of temperature independence of these parameters for line 1 in figure 8.

Another observation regarding line 1 in our samples is that the intensity of this line weakens as the size of the Ni NPs increases (see figures 2–4). As noted earlier (figure 1), the annealing temperature determines the size of the Ni NPs in that higher annealing temperature yields particles of larger  $D$ . To verify whether a higher annealing temperature might be quenching the paramagnetic defects responsible for line 1 in the larger sizes of the Ni NPs, a sample of undoped  $\text{SiO}_2$  annealed at  $800^\circ\text{C}$  was also prepared. In figure 9, the EMR signals observed from samples of  $\text{SiO}_2$  annealed at  $400$  and  $800^\circ\text{C}$  are compared. Indeed, the EMR signal observed in the  $800^\circ\text{C}$  annealed sample is nearly two orders of magnitude weaker, thus explaining our observations of the size dependence of the intensity of line 1 in the Ni/ $\text{SiO}_2$  samples.

Although the temperature dependence of the EMR of line 1 in the  $3.8$  nm Ni/ $\text{SiO}_2$  and undoped  $\text{SiO}_2$  is similar (figure 8), the magnitude of  $\Delta H$  for line 1 in the  $3.8$  nm sample of



**Figure 9.** Comparison of the line profiles of line 1 measured at 300 K for the undoped samples of SiO<sub>2</sub> annealed at 400 and 800 °C.

Ni/SiO<sub>2</sub> is larger ( $\Delta H \approx 50$  Oe) than  $\Delta H \approx 9$  Oe for the line observed in the undoped SiO<sub>2</sub>. This larger  $\Delta H$  for line 1 in Ni/SiO<sub>2</sub> is likely due to the effect of dipole interaction on the paramagnetic defects from the neighboring Ni nanoparticles. In this study, the nature of the paramagnetic defects responsible for line 1 was not explored since there is considerable literature on the various EMR active paramagnetic defects in amorphous silica [18] and the nature of the defect is not relevant to the main subject of this paper, namely the EMR spectra due to Ni NPs.

### 5. Theoretical considerations for lines 2 and 3

Prior to the interpretation of the EMR parameters for lines 2 and 3, it is useful to summarize the results from relevant theoretical models and the known relevant properties of bulk Ni. FCC Ni (density = 8.91 g cm<sup>-3</sup>, lattice constant = 3.52 Å) is a ferromagnet with  $T_C = 631$  K,  $\langle 111 \rangle$  directions as the easy axes and saturation magnetization  $M_S = 510(485)$  emu cm<sup>-3</sup> near 0 K (293 K). The first-order anisotropy constant  $K_1$  is negative with magnitudes =  $7.5 \times 10^5 (5 \times 10^4)$  ergs cm<sup>-3</sup> at 20 K (293 K) [19]. The above magnitudes yield the effective anisotropy field  $H_A = -(2K_1/M_S) = 1470$  Oe (103 Oe) near 20 K (293 K). The negative sign of anisotropy constant  $K_1$  merely reflects the fact that, in bulk Ni,  $\langle 111 \rangle$  is the easy direction of magnetization rather than the  $\langle 100 \rangle$  direction.

In the earlier EMR studies of polycrystalline bulk ferromagnets, the resonance field was successfully fitted to the equation  $H_r = (\omega/\gamma) - H_i$ , where  $H_i$  is an effective internal field,  $\omega = 2\pi f_m$  and  $\gamma = 2\pi g\mu_B/h$  [20]. For the magnetocrystalline anisotropy of cubic systems,  $H_i = -2K_1/M_S = H_A$ . For bulk Ni,  $K_1$  is negative and so  $H_A$  is positive, leading to a shift of the line to lower fields. If  $H < H_A$ , two lines are often present. The lower (higher) field peak belongs to grains with magnetization parallel to the easy axis (the applied field).

The above results suitable for bulk Ni cannot be directly applied to EMR in Ni NPs first because magnitudes of  $K_1$  are larger for the smaller particles [12] and second because  $H_A$  is reduced with increasing temperatures due to the effect of superparamagnetism [6, 21]. Raikher and Stepanov (RS) have presented a model on the effect of thermal fluctuations on the FMR lineshapes in dispersed ferromagnetic nanoparticle systems for the uniaxial and cubic ( $K_1 < 0$  and  $K_1 > 0$ ) symmetries [22]. Therefore the RS model is a relevant one for comparison with our experimental results in the Ni NPs.

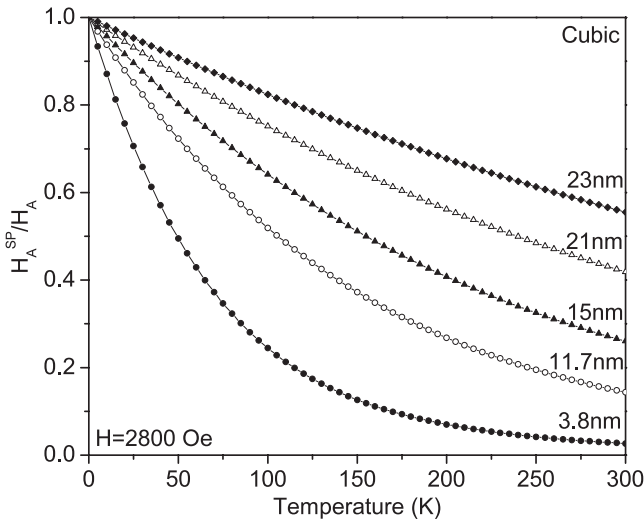
As noted by RS [22], the calculations require ‘averaging not only over the statistical ensemble of particles with a given direction of the anisotropy axis, but also over the angular distribution of the anisotropy axis in such a particle.’ In [21], only the first averaging was carried out. Since this analysis of [21] provides considerable insight into the size and temperature dependence of the anisotropy, we apply it to our Ni NPs to show how temperature and size dependence of  $H_A^{SP}$  (superparamagnetic) relative to bulk  $H_A$  changes with temperature due to the effect of superparamagnetism of Ni NPs. The more complete analysis of the RS model makes the following major predictions which are tested, at least qualitatively, in this work on the Ni NPs:

- (i) With decreasing temperature, the EMR absorption becomes increasingly asymmetric, resulting in the appearance of two lines in the experimental absorption derivative. The separation between the two lines in the absorption derivative increases with the decrease in temperature.
- (ii) Beginning at the lowest temperature, the linewidth  $\Delta H$  decreases with increase in temperature (irrespective of the type or the sign of anisotropy constant), reaches a minimum at a certain temperature and then, at high enough temperatures,  $\Delta H$  of the now symmetric line is predicted to increase with increase in temperature.
- (iii) The resonance field  $H_r$ , defined by the zero of the absorption derivative of the higher field line, is predicted to decrease with decreasing temperatures for cubic systems with  $K_1 < 0$  but increase for systems with  $K_1 > 0$ .

The effect of averaging over the angle  $\theta$  between the magnetic moment and the magnetic field, done in [21], leads to the following ratio of  $H_A^{SP}/H_A$  (bulk) for cubic anisotropy:

$$\frac{H_A^{SP}}{H_A} = \frac{1 - 10x^{-1} \coth(x) + 45x^{-2} - 105x^{-3} \coth(x) + 105x^{-4}}{\coth(x) - x^{-1}} \quad (1)$$

Here  $H_A$  is the anisotropy field for bulk Ni and  $x = M_S V H / kT$  with  $V$  being the volume of the nanoparticle with intrinsic moment  $M_S$  and  $k$  the Boltzmann constant. In figure 10, the computed plots of  $H_A^{SP}/H_A$  versus  $T$  are shown for the different sizes of NPs investigated in this work using  $H = 2800$  Oe, the field close to  $H_r$  for line 2. These plots are valid for the superparamagnetic regime only, namely  $T > T_B$  (EMR). It is evident from figure 10 that, with the decrease in temperature,  $H_A^{SP}$  increases for all the particles. Of course in



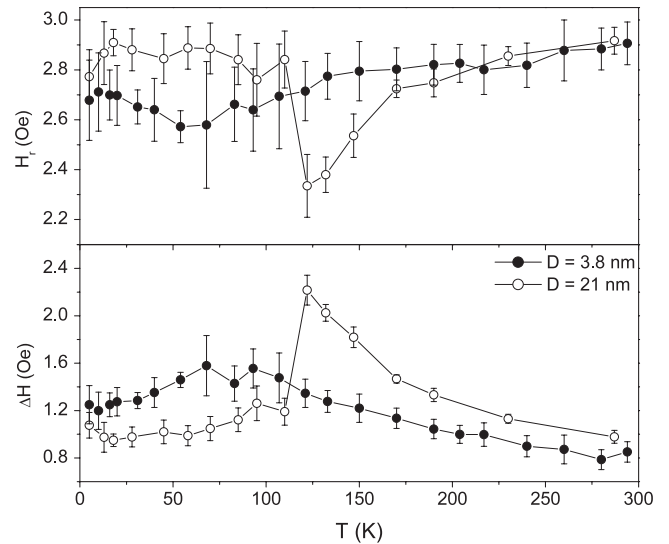
**Figure 10.** Plots of  $H_A^{SP}/H_A$  for the sizes of Ni NPs shown versus temperature using equation (1). Magnitude of  $H = 2800$  Oe close to  $H_r$  for line 2 is used in the calculations.

our case,  $T_B$  (EMR)  $> 90$  K for all the particles and data for temperatures above  $T_B$  only can be compared with the predictions of equation (1).

### 6. Interpretation of lines 2 and 3

In the earlier EMR work of Sharma and Baiker in the Ni/SiO<sub>2</sub> system [6], a weaker absorption at lower fields and lower temperatures only, somewhat similar to line 3 reported here, was observed in addition to the main line near  $g = 2.25$ . This lower field absorption was suggested to result from the larger blocked particles in the ferromagnetic state. The more intense line near  $g = 2.25$  is then from the majority of the Ni NPs which go through the superparamagnetism to ferromagnetic state as the temperature is lowered. In this interpretation, lines 2 and 3 are treated as distinct entities. Since this may be a reasonable interpretation, although different from the RS model, it is first followed in the interpretation of the data below. A comparison and critique of these two models is given later.

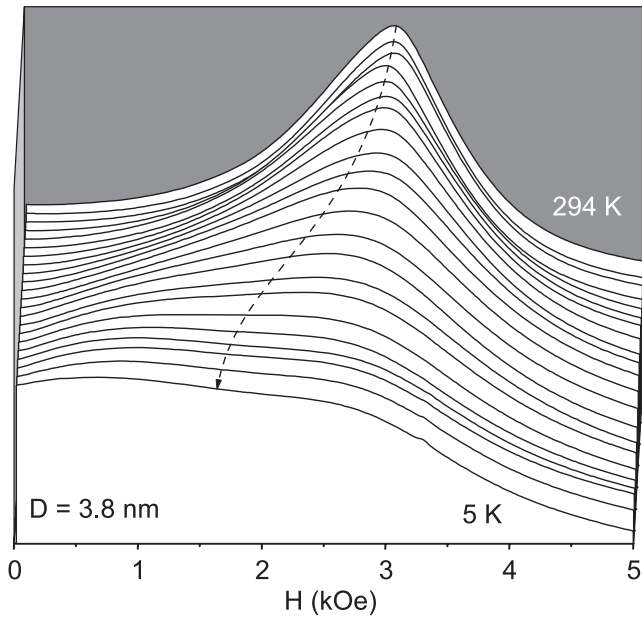
The temperature dependence of the EMR parameters for the two representative samples with  $D = 3.8$  nm and 21 nm were given earlier in figures 5 and 6, respectively. A common feature of the data in figures 5 and 6 and for the remaining samples with different sizes [13] is that, with the decrease in temperature from 300 K, the intensity  $I_o$ , linewidth  $\Delta H$  and lineshift  $\delta H_r = H_r(300 \text{ K}) - H_r(T)$  for line 2 increase with the decrease in  $T$ , reaching maximum values at a certain temperature  $T_B$  (EMR). For  $T < T_B$  (EMR),  $I_o$  and  $\Delta H$  decrease with decrease in  $T$  whereas  $H_r$  is nearly temperature-independent within experimental uncertainties. We associate  $T_B$  (EMR) with the blocking temperature measured at 9.28 GHz and at the resonance field  $H_r$ . For  $T > T_B$  (EMR), the particles are in the superparamagnetic state whereas for  $T < T_B$  (EMR), the Ni spins appear blocked at the 9.28 GHz frequency, resembling ferromagnetism.



**Figure 11.** Comparison of the temperature dependence of  $H_r$  and  $\Delta H$  for line 2 in the 3.8 and 21 nm samples of Ni/SiO<sub>2</sub>. Lines joining the points are for a visual aid.

For the 3.8 nm sample, a detailed investigation of the variation of  $T_B$  measured at  $f_m = 1$  Hz and in different magnetic fields  $H$  yielded the variation  $T_B(H) = 33(1 - H/H_o)^m$  with  $H_o = 3200$  Oe and  $m = 2(3/2)$  for lower (higher) fields, in agreement with theoretical predictions [11]. This rapid decrease of  $T_B$  with increasing  $H$  implies that  $T_B$  (EMR) measured in  $H_r$  should be considerably lower than the theoretical estimate calculated for  $f_m = 9.28$  GHz in zero  $H$  based on the equation  $T_B = T_o + T_a/\ln(f_o/f_m)$ . Here  $T_o$  represents the interparticle interaction,  $T_a = K_a V/k_B$  and  $f_o = 1.8 \times 10^{10}$  Hz for the Ni/SiO<sub>2</sub> system [12]. Using the data of [12] for  $T_o = 0, 0, 6.6$  and  $12.5$  K and  $T_a = 310, 954, 1334$  and  $1405$  K yields  $T_B$  (EMR) = 460, 1416, 1987 and 2098 K for  $H_r = 0$ , respectively, for the  $D = 3.8, 11.7, 15$  and 21 nm samples. To determine the effect of the applied field  $H_r$  on  $T_B$  (EMR), we use the theoretical fit of  $T_B(H)/T_B(0)$  versus  $H$  from [11], which gives  $T_B(H)/T_B(0) \approx 0.08$  at  $H = H_r$ . This yields  $T_B$  (EMR) at  $H = H_r$  equal to 37, 113, 160 and 168 K, which compares favorably with the experimental  $T_B$  (EMR) = 90, 115, 155 and 122 K, respectively for the  $D = 3.8, 11.7, 15$  and 21 nm samples. Thus the measured values of  $T_B$  (EMR) can be explained satisfactorily once the magnetic field dependence of  $T_B$  (EMR) is taken into account.

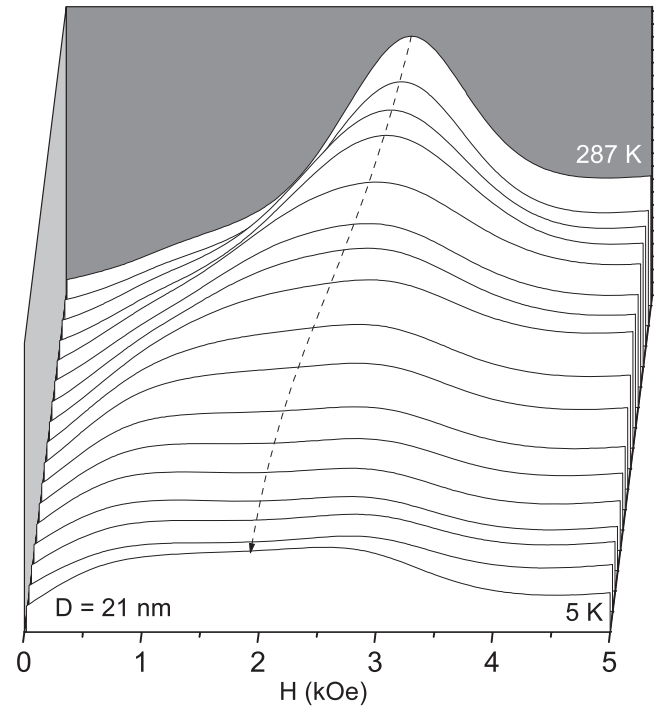
The decrease of  $H_A^{SP}$  with increasing temperatures for all sizes due to increasing thermal fluctuations in figure 10 can be used to qualitatively explain the temperature dependence of  $\Delta H$  and  $H_r$  for  $T > T_B$  (EMR). Since  $H_A$  and hence  $H_A^{SP}$  are both positive for Ni, the line shifts to lower fields following our earlier discussion in section 5. Also, since anisotropy increases with decreasing temperatures in figure 10,  $H_r$  is predicted to decrease with decreasing temperature as observed experimentally. Furthermore, anisotropy also increases the linewidth  $\Delta H$  if the anisotropy does not commute with the magnetization  $M_Z$  measured along the direction of applied field  $H_r$  [20, 23, 24]. Therefore  $\Delta H$  should also increase with decreasing temperatures. These effects of decreasing  $H_r$  and



**Figure 12.** EMR absorption spectra obtained by integration of the experimental derivative spectra of figure 3 for  $D = 3.8$  nm NPs. The dotted line is drawn connecting the center of the composite spectra.

increasing  $\Delta H$  on lowering the temperature are observed here for NPs of Ni (figures 5 and 6). For the two representative sizes of  $D = 3.8$  and 21 nm, the temperature dependences of  $\Delta H$  and  $H_r$  shown in figure 11 are consistent with this prediction. Also the larger magnitude of  $\Delta H$  in the 21 nm vis-à-vis 3.8 nm is consistent with the predicted higher anisotropy of the 21 nm particles (figure 10). Although these magnitudes of  $\Delta H$  are comparable to  $H_A = 1470$  Oe calculated earlier for bulk Ni at lower temperatures, the anisotropy in Ni NPs is affected by several other factors noted above.

To determine whether demagnetizing effects due to any deviations from spherical symmetry of the Ni NPs might be affecting our observations, we measured EMR of a polycrystalline Ni thin foil of thickness 0.01 mm at room temperature. For in-plane EMR at 9.28 GHz, we measured  $H_r \approx 1300$  Oe with  $\Delta H \approx 1600$  Oe where, for  $H \perp$  plane,  $H_r \approx 8500$  Oe with a highly asymmetric line. Assuming  $M_s = 485$  emu cm $^{-3}$  for bulk Ni at 293 K and demagnetizing factors of  $N_{\parallel} = 0$  and  $N_{\perp} = 4\pi$ , the Kittel equations yield  $H_r(\parallel) \approx 1240$  Oe for in-plane and  $H_r(\perp) \approx 9108$  Oe resonance fields [25]. The slight deviations of the experimental values from the above magnitudes are most likely due to the finite thickness of the foil, leading to  $N_{\parallel} > 0$  and  $N_{\perp} < 4\pi$ . For the thin film, shape is the leading source of anisotropy, yielding departures from the expected  $g = 2.25$  for Ni. In the Ni NPs, we observe  $g \approx 2.25$  for all of our samples at room temperature suggesting negligible effects of any shape anisotropy on the EMR spectra. These results also show that  $H_r \approx 700$  Oe for line 3 in figures 12 and 13 cannot be explained just in terms of the shifts due to demagnetizing effects in a ferromagnetic particle since  $H_r \approx 1240$  Oe for in-plane resonance in a thin film, which provides the maximum possible shift due to a demagnetization factor, is larger than 700 Oe. In

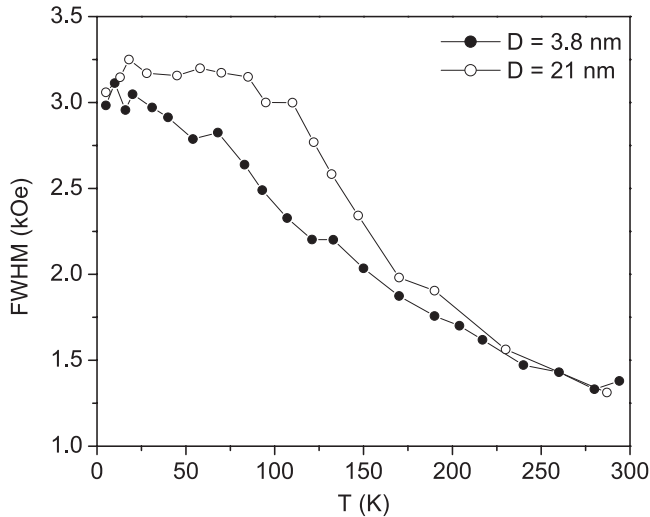


**Figure 13.** Absorption spectra for the  $D = 21$  nm NPs obtained by integration of the experimental derivative EMR spectra of figure 4. The dotted line is drawn connecting the center of the composite two-line spectra

addition, line 3 is observed even in the smallest 3.8 nm particle which is unlikely to have any large clusters of Ni NPs. For these reasons, large blocked particles as the source of line 3 can be ruled out.

Next, our experimental results are compared with some of the predictions of the RS model. For this comparison, we have integrated the spectra of figures 3 and 4 to yield absorption curves of figures 12 and 13 for the 3.8 nm and 21 nm systems, respectively. According to the RS model, line 3 appears as a result of the averaging over the angular distribution of the anisotropy axis in NPs and so it is an integral part of line 2 which results in an asymmetric lineshape as temperature is lowered. This is clearly observed in figures 12 and 13. The temperature dependence of the resonance field  $H_r$  shown in figures 5, 6 and 11 is still valid since  $H_r$  in the RS model is determined by the field position of zero intensity in the derivative spectra of line 2. In figures 12 and 13, the dotted lines are drawn connecting the center of the composite absorption spectra which also shifts to lower magnetic fields with decreasing temperatures. In the RS model, linewidth is defined as the field separation between the minimum of line 2 and the maximum of line 3 in the absorption derivative. This separation in figures 3 and 4 does decrease with the increase in temperature. However, the peak of line 3 is difficult to define at many temperatures. Therefore, for the linewidth of the composite line, we measured FWHM (full width at half-maxima) of the absorption spectra in figures 12 and 13. The temperature dependence of the FWHM linewidth so measured is shown in figure 14 for the 3.8 and 21 nm particles. The decrease in the linewidth with increasing temperatures



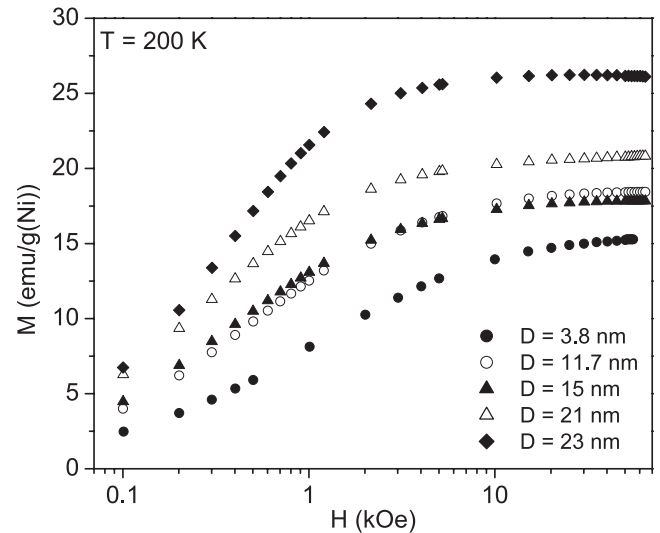


**Figure 14.** Temperature dependence of the linewidth FWHM (full width at half-maxima) of the composite line for the  $D = 3.8$  and  $21$  nm NPs. Lines joining the points are for a visual aid.

predicted in the RS model is clearly observed with a clear minimum near  $300$  K, at least for the smaller  $3.8$  nm particles. This result, along with the decreasing asymmetry with increasing temperatures and temperature dependence of  $H_r$ , is in agreement with the predictions of the RS model for a cubic system with negative  $K_1$  as noted earlier. Experiments at still higher temperatures are needed to determine the predicted increase in linewidth for  $T > 300$  K.

There have been a number of other nanoparticle systems where similarly increasing  $\Delta H$  and lineshifts  $\delta H_r$  with decreasing temperatures have been reported [26–31]. Nagata and Ishihara [26] while considering the case of shape anisotropy due to an ellipsoidal particle showed that lineshift ( $\delta H_r$ ) is proportional to  $(\Delta H)^n$ , where  $n = 3$  for randomly oriented particles and  $n = 2$  for partially oriented particles. For NPs of NiO [31], Mn–Zn ferrite [26], ferrihydrite [28] and Si-doped ferrihydrite [29],  $n = 3$  has been experimentally observed. However, these systems have dominant antiferromagnetic coupling and the EMR is due to uncompensated magnetic moments on the surface of the NPs. Therefore, results from these systems cannot be compared with our results in Ni NPs, bulk Ni being a ferromagnet.

An alternative approach to the line narrowing observed in NPs with increasing temperature was developed by Morais *et al* [32, 33] using the van Vleck moment method. For isolated NPs interacting only by long-range dipole interaction, this model predicted  $\Delta H$  varying as  $\tanh(\Delta E/2kT)$ , with  $\Delta E$  being an activation energy whereas for an interacting spin system including exchange and dipole interactions, this model predicts  $\Delta H$  varying as  $\exp(-T/T_f)$ . Both of these variations predict decreasing  $\Delta H$  with increasing  $T$  but  $\exp(-T/T_f)$  represents a more rapid variation [33]. These models, however, did not address the question of changes in  $H_r$  with changing temperature which has been observed here as well as in many systems of NPs [26–31]. Therefore, this model is not used here to analyze the experimental results on the Ni NPs.



**Figure 15.** Variations of static magnetization  $M$  with applied field  $H$  at  $200$  K for the particle sizes shown.

Finally in figure 15, the plots of  $M$  versus  $H$  at  $200$  K for all five samples of Ni NPs show a decrease in the saturation magnetization  $M_s$  with decrease in particle size, similar to the recent observations in  $\text{Fe}_3\text{O}_4$  NPs [34]. Similar variation with  $D$  is observed at  $5$  K [13]. In figure 15, the maximum magnitude of  $M_s = 27$   $\text{emu g}^{-1}$  (Ni) for the  $D = 23$  nm sample is only half the magnitude of  $54$   $\text{emu g}^{-1}$  for bulk Ni. Following [34], this decrease in  $M_s$  can be interpreted in terms of a magnetically silent surface layer of Ni atoms as a result of the reduced symmetry and reduced exchange coupling of the surface spins to the spins in the bulk of an NP. Consequently, the surface spins are often disordered and so they do not contribute to  $M_s$ . For the Ni/SiO<sub>2</sub> system, this effect may be even more enhanced if there is likely some chemical coupling between the surface Ni atoms and the surrounding SiO<sub>2</sub> matrix, thus affecting the magnetism of the surface Ni atoms. However, the surface Ni atoms are not the likely source of line 3 since their effect would then have been more enhanced in the smaller  $3.8$  nm particles, similar to the large reduction in their magnetization seen in figure 15. This is so because the fraction of surface spins varies as  $1/D$ , thus increasing with decrease in  $D$ . Comparing the EMR profiles in figures 2–4 for different sizes, the intensity of line 3 certainly does not increase with decreasing  $D$ . Besides, the RS model [22] seems to provide an adequate description of the temperature dependence of line 2 and line 3 as discussed above.

## 7. Concluding remarks

Analysis of the experimental results on the temperature dependence of the three EMR lines observed in the nanocomposite Ni/SiO<sub>2</sub> (15/85) has been presented. Two of the lines (lines 2 and 3) are assigned to the Ni NPs and the third narrower line near  $g = 2.00$  is attributed to paramagnetic defects in the amorphous SiO<sub>2</sub> matrix. Two models are used to interpret the temperature variation of  $H_r$  and  $\Delta H$  for lines 2 and 3 assigned to Ni NPs. In the first model following Sharma

and Baiker [6], line 2 near  $g = 2.2$  is assigned to the majority of the Ni NPs which, upon decreasing the temperature, go through a transition from the superparamagnetic to the blocked ferromagnetic state and line 3 near  $g \approx 8$  is assigned to larger clusters of NPs which are in the blocked state even at 300 K. However, the large  $g$  value of line 3 and its dependence on particle size is difficult to explain in this model. In the second RS model based on the theory of Raikher and Stepanov [22], line 3 is a part of the inhomogeneously broadened asymmetric line 2 in the EMR absorption which appears as a separate line when the field derivative of absorption is measured in the experimental EMR spectra. Furthermore, the RS model predicts that, with increasing temperature, the composite line becomes more symmetric, its  $H_r$  increases and  $\Delta H$  decreases in cubic systems with negative anisotropy such as Ni. The results presented here on Ni NPs provide strong support for these predictions. The RS model also predicts  $\Delta H$  to reach a minimum at higher temperatures as observed here in the Ni NPs near 300 K. However, two additional predictions of the RS model remained untested. First, the RS model predicts increasing  $H_r$  with decreasing temperatures in a cubic system with positive anisotropy constant such as Fe NPs; and second  $\Delta H$  is predicted to increase with increasing temperatures above the minimum near 300 K. In the work of Sharma and Baiker [6], a hint of increasing  $\Delta H$  near 300 K was reported. However, we are not aware of any experimental work on the temperature dependence of the EMR parameter in Fe NPs to test the remaining prediction of the RS model.

In summary, the RS model provides a satisfactory explanation of the experimental results presented here on the Ni NPs. Verification of the other predictions of the RS model noted above will be undertaken in our future work. Establishing the SiO<sub>2</sub> matrix as the source of the narrow line whose linewidth and line position do not change with temperature is another important contribution of the results presented in this paper. Nanoparticles of Ni with high dispersion on a catalyst support such as SiO<sub>2</sub> and Al<sub>2</sub>O<sub>3</sub> are excellent catalysts for various hydrogenation and hydrogenolysis reactions [3]. The method of synthesis and the corresponding properties of the Ni/SiO<sub>2</sub> nanocomposites with different dispersions of Ni presented here provide a good resource for future such applications.

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